

IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



In re Application of
Seiji NAGAI

Serial No.: 10/662,809

Group Art Unit: 1722

Filed: September 16, 2003

Examiner: Rao, Nagesh G.

For: METHOD FOR PRODUCING GROUP III NITRIDE COMPOUND
SEMICONDUCTOR SUBSTRATE

Honorable Commissioner of Patents
Alexandria, VA 22313-1450

REQUEST FOR RECONSIDERATION UNDER 37 C.F.R. §1.111

Sir:

In response to the Office Action dated April 4, 2007, please amend the above-identified application as follows:

INTRODUCTORY COMMENTS

Remarks begin on page 2 of this paper.